Scanning Tunneling Microscopy Investigation of Silver Deposition upon Au(111) in the Presence of Chloride

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Received April 30, 2002

Using electrochemical measurements and in situ scanning tunneling microscopy (STM), we confirm the process of Ag growth and the overlayer structures of Ag underpotential deposition (upd) on Au(111) in the presence or absence of chloride anions. There are four distinct structures of the Ag adlayer on Au(111) in the presence of chloride. Adlayer structures (\(\sqrt{3} \times \sqrt{3}\)R30°, (\(\sqrt{19} \times \sqrt{19}\)R37°, (\(\sqrt{13} \times \sqrt{13}\)R46°, and (6 x 6) are formed as a function of potential, and these structures are clearly matched to the features in a cyclic voltammogram. Compared with the (4 x 4) structure of Ag upd on Au(111) in a pure 0.1 M HClO\(_4\) solution, overlayer structures of Ag on Au(111) in a chloride-containing solution are more loosely packed. Therefore, we conclude that the structures of the Ag overlayer on Au(111) strongly interact with chloride anions, suggesting the bilayer structure is composed of both Ag and Cl.

1. Introduction

Since the application of the scanning tunneling microscopy (STM) in an aqueous environment pioneered by Sonnenfeld and Hansma\(^1\) in 1986, electrochemists have possessed abilities to observe a surface process with real-space images at the electrified solid—liquid interface. Using these abilities, multifarious results were reported about the reconstruction of metal surfaces,\(^2\)\(^3\) the adsorption on metal surfaces,\(^4\)\(^5\) corrosion,\(^6\)\(^7\) and growth phenomena of metals,\(^8\) which were all obtained under the potential control.\(^9\)\(^10\) Among them, one of the most successful studies is the investigation of underpotential deposition (upd).\(^11\)\(^12\) The research of upd systems triggers interests in fundamental as well as technical aspects such as catalysts,\(^13\)\(^14\) thin-films,\(^15\)\(^16\) sensors,\(^17\) and the modification of metal surfaces.\(^18\)\(^19\) Among the numerous upd systems that have been characterized, silver upd on gold is one of the most widely studied. GeWirth et al. reported the Ag upd on Au(111) by using in situ AFM, where the structure was dependent on the nature of the electrolyte. They observed a (3 x 3) adlayer of Ag upd in sulfate, a (4 x 4) overlayer in nitrate- and carbonate-containing electrolytes, and a complex structure in perchlorate after the first peak of Ag upd.\(^20\)\(^22\) Unlike these, Itaya et al. found a (\(\sqrt{3} \times \sqrt{3}\)R30°) structure for the upd of Ag onto Au(111) in sulfate and a (4 x 4) overlayer in a perchlorate-containing solution posterior to the first upd peak.\(^21\)\(^23\) The different results of each group may stem not only from the use of similar tools (STM, AFM) but also from the effect of the trace amounts of contaminated anions. Especially, chloride may be one of the most serious interferences in the Ag upd system.

Using electrochemical techniques and X-ray photoelectron spectroscopy (XPS), Laibinis et al. showed that repetitive underpotential deposition and stripping of Ag on Au(111) in a sulfate solution with the trace amounts of chloride anions caused an increase of nobility of Ag upd.\(^24\) They concluded that the transformation toward a much nobler Au(111) substrate resulted from the adsorption of chloride on silver during Ag upd and that of chloride on gold during stripping of an Ag adlayer, conceiving that halide ions strongly contribute to the formation of Ag adlayer structures. Therefore, two goals of our study of the Ag upd in the presence of halide are the investigation for a strong dependency on the counterion in the overlayer structure and the definitive determination of the Ag adlayer structure in pure sulfate- or perchlorate-containing electrolytes. However, there is no research about Ag upd onto Au(111) in the presence of halide anions such as chloride and iodide because of the low solubility of silver halide salts in aqueous media and other solvents.

In this paper, we report several stepwise stages of Ag growth and of atomic Ag structures on Au(111) in the presence of chloride.

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presence/absence of chloride. Because we could not overcome the inherently low solubility of AgCl, we used a low concentration of Ag⁺ ions (≈ \(10^{-5}\) M). Since the underpotential deposition of metal adatoms on a metal substrate is a thermodynamic process, which is associated with work functions of an adatom and a substrate, we deduce that the concentration \(10^{-5}\) M must be acceptable. We expect that our observations will accelerate studies of metal upd systems in the presence of halide, which are less investigated because of the poor solubility of metal halide salts in water.

2. Experimental Section

Materials. The working electrode for electrochemical measurements was an Au(111) single crystal (MaTeck, Germany) with a diameter of 1 cm and a nominal area of 0.785 cm². For STM imaging, Au (thickness 250 ± 50 nm) substrates evaporated onto glass with Cr-adhesion layers (thickness ~3 nm) were obtained from Metalhandel Schroer GmbH, Germany. All Au electrodes were annealed for 3 min in a hydrogen flame prior to use and slowly cooled in air, following a published procedure.

Oxide formation and stripping voltammetry of the surface in pure electrolyte were found to closely match the literature for an Au(111) surface. Electrochemical solutions were prepared from ultrapure water (Modulab, US Filter, MA, 18 MΩ). AgClO₄•H₂O (99.99%), AgCl (99.99%), and HClO₄ (double-distilled) were all obtained from Aldrich. A chloride-containing solution was prepared by sonicating AgCl salts for at least 3 h (Branson Ultrasonics Co.) because of the low solubility. This solution was saturated with Ag⁺ and Cl⁻ ions of \(\approx 10^{-5}\) M concentration.

Electrochemical Measurements. Cyclic voltammetry was acquired using a Pt (99.99%, 0.5-cm diam, Aldrich) wire as a counter electrode and a saturated mercury-mercurous sulfate electrode (MSE) as a reference electrode connected to the electrochemical compartment via a capillary salt bridge to lessen contamination from the reference electrode. All potentials in this paper are quoted relative to the MSE (0.64 V vs NHE).

The solutions were purged with Ar prior to use, and the atmosphere of an electrochemical cell was blanketed with Ar during all electrochemical measurements. Potential control and sweeps were conducted with an Autolab potentiostat (PGSTAT 10, ECOChemie, Netherlands).

Scanning Tunneling Microscopy. STM images were collected in a constant current mode with Topometrix TMX 2000. A silver wire (99.99%, 0.5-cm diam, Aldrich) was employed for the reference electrode, while a Pt wire was used as the counter electrode. The scanner was calibrated against the lattice spacing of a highly ordered pyrolytic graphite (HOPG) surface in air for in-plane dimensions and against monatomic Au(111) steps for dimensions normal to the surface. The scanner was always stabilized for half a day to minimize thermal or acoustic vibrations before STM imaging and x, y, z-calibration. An electrochemically etched Pt/Ir wire (Molecular Imaging, AR) coated with Apeizon wax or polyethylene was used as the STM tip. All images are presented as unfiltered forms.

3. Results and Analysis

3.1. Electrochemical Measurements. 3.1.1. In the Absence of Cl⁻. Figure 1 shows a cyclic voltammogram and a coulometric curve (inset) of Ag upd on an Au(111) single crystal in 1 mM AgClO₄ and 0.1 M HClO₄. This voltammogram and the corresponding coulometric curve are nearly identical to those in the previous work. A first cathodic peak (C1) appears at 0.560 V, and the corresponding anodic peak (A1) is observed at 0.570 V. Another cathodic peak (C2) is seen at around 0.007 V with a shoulder peak (C3) at −0.025 V. The reversible desorption (A2) of the second Ag upd occurs at 0.011 V with a shoulder peak (A3) at −0.014 V. This pair of shoulders (C2 and A2), not previously reported, is highly reversible. After the third peak of Ag upd, the cathodic current suddenly increases at −0.04 V, denoting the commencement of bulk Ag deposition. All features in this voltammogram are stable during several cycles, confirming that alloy formation between Ag and Au in the upd region does not occur.

A coulometric curve during Ag deposition is shown in the inset of Figure 1. To deposit a monolayer of Ag on Au(111), the charge density 222 μC/cm² is required under the assumption that the deposition of Ag is a process of one-electron transfer per silver ion. The amounts of charge density up to the C, C2, and C3 peaks within the Ag upd region are 46, 298, and 345 μC/cm², respectively. The amounts of surface coverage up to the C1, C2, and C3 peaks are 0.21, 1.34, and 1.55, respectively. A monolayer of Ag is completed at −0.002 V around the C2 peak, while a total value of 1.55 connotes that the second adlayer of Ag on Au(111) is present.

3.1.2. In the Presence of Cl⁻. Figure 2 shows a cyclic voltammogram and the corresponding coulometric curve (inset) obtained in a 0.1 M HClO₄ solution with saturated AgCl on an Au(111) single crystal. Five sets of adsorption and desorption peaks conform to several typical stages of Ag upd onto Au(111). A cathodic peak (C3) of the first Ag upd begins to increase at 0.5 V and is split into two peaks, one electron-transfer per silver ion. The corresponding anodic peak (A3) starts to increase at 0.400 V and is also divided into two peaks which occur at 0.438 and 0.519 V. When the potential changed to 0.63 V, an Au(111) electrode surface was oxidized, yielding a specific voltammetric response that was substantially identical to that observed in a pure HClO₄ solution. This verifies that the aforementioned set of peaks (C1 and A1) corresponds to the first adsorption and desorption of Ag on the Au(111) electrode.

The cathodic peaks of C2, C3, and C4 for deposition are shown at 0.095, −0.031, and −0.105 V, while the corresponding anodic peaks of A2, A3, and A4 for stripping emerge at 0.166, 0.017, and −0.029 V, respectively. The differences between the cathodic peak potentials and the anodic peak potentials for the three series of peaks (C2, C3, and C4) for deposition are shown at 0.095, −0.031, and −0.105 V, while the corresponding anodic peaks of A2, A3, and A4 for stripping emerge at 0.166, 0.017, and −0.029 V, respectively.
and $A_2$, $C_3$ and $A_3$, $C_4$ and $A_4$) are 0.071, 0.048, and 0.076 V, respectively. This peak separation points out the irreversible behavior of Ag upd onto Au(111) in the presence of chloride, compared with nearly symmetric peaks in Ag upd in the absence of chloride (see Figure 1). These results may be due to the low concentration of Ag ions and the competitive adsorption/desorption of chloride anions. In the bulk deposition realm, there are two distinctive regions. The deposition of Ag occurs at $-0.194$ V ($C_3$), and the additional deposition appears posterior to $-0.4$ V. The corresponding stripping peak of Ag ($A_3$) is seen at $-0.090$ V. As a control experiment, cyclic voltammetry was conducted in a pure HClO$_4$ solution in which Ag upd. Thus, a monolayer of Ag is completed at a surface coverage of 1.31 prior to hydrogen evolution at 0.03, 0.21, 0.26, 0.32, and 0.49, respectively, with the total charge density of 290 $\text{C/cm}^2$ to the limit of $0.6$ V. The amounts of charge density were intergrated obtained from a cyclic voltammogram during a cathodic sweep. The inset in Figure 2 displays a coulometric curve corresponding to the cyclic voltammogram during a cathodic sweep.

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3.2.1. Ag Growth on Au(111) in the Absence of Cl$^-$: Figure 3 shows consecutive STM images of an Au(111) electrode under various potentials in 1 mM AgClO$_4$ and 0.1 M HClO$_4$.

![Figure 2. Cyclic voltammogram in saturated AgCl and 0.1 M HClO$_4$ on an Au(111) single crystal. Scan rate = 2 mVs. Inset: a coulometric curve corresponding to the cyclic voltammogram during a cathodic sweep.](image)

![Figure 3. 190 x 190 nm$^2$ STM images in a solution containing 1 mM AgClO$_4$ and 0.1 M HClO$_4$. (A) STM image of Ag islands on Au(111) terraces at $E = 0.46$ V. $I_{\text{tip}} = 2$ nA. $E_{\text{bias}} = 200$ mV. Arrows indicate Ag islands. (B) Lateral growth of Ag on Au(111) terraces at $E = 0.01$ V. $I_{\text{tip}} = 2$ nA. $E_{\text{bias}} = 650$ mV. (C) A complete monolayer of Ag on Au(111) at $E = -0.02$ V. $I_{\text{tip}} = 2$ nA. $E_{\text{bias}} = 680$ mV. (D) The second Ag Islands on Au(111) at $E = -0.035$ V. $I_{\text{tip}} = 3$ nA. $E_{\text{bias}} = 700$ mV.](image)
As the potential is moved to $-0.12$ V, decorated Au(111) steps by additional Ag deposition are clearly seen in Figure 4B. The edge decoration of Au(111) steps is evenly distributed at all steps of an Au(111) substrate, which was also observed for Cu upd on Au(111). This feature indicates that the diffusion-limited control mainly dominates the Ag growth, and silver at low concentration favors the energetically most stable site, such as a step. The deposition at local step sites is more clearly visualized in the profile in Figure 4C, which is taken along the line marked in Figure 4B. The height of the edge decoration is measured to be $0.36 \pm 0.03$ nm, which denotes another adlayer on the predeposited Ag upon an Au(111) substrate.

To investigate the role of chloride more deeply, an Au-adlayer on the predeposited Ag upon an Au(111) substrate. When the potential was stepped to the positive value, the Ag islands are formed, and the step sites of a substrate are fluctuated. Primitively, these results were surprising and were not easily understood. However, the existence of chloride reveals a clue to unite these entanglements. If the potential is stepped to $0.12$ V, which is more clearly visualized in the inset of Figure 4F. Compared with the stripping of the Ag adlayer in pure electrolytes only with Ag$^+$ ions, the AgCl adsorption plays an important role in edge decoration.

Figure 4D displays an STM image of Ag-deposited Au(111) terraces obtained at $-0.38$ V. A large Ag island, designated by a solid-lined arrow, and a bunch of small islands are distinctly seen with the highest brightness. If the closely zoomed in Ag islands, there are many pits, demonstrating that the Ag adlayers are loosely packed and are coalescing during a growth process. The upper and outer parts of the Au(111) steps (see dashed arrows in Figure 4D) are much brighter than the inner Au(111) terrace, indicating the maintenance of the edge decoration at the Au(111) steps. Also, horizontally grown bumps shown at step sites represent the lateral growth of Ag. A full monolayer of Ag and additional Ag islands on an Au(111) surface are obviously observed at $-0.53$ V in Figure 4E when the charge density is $210 \mu$C/cm$^2$, as described in the inset of Figure 2. The Ag overlayer keeps a similar morphology to that of the image in Figure 4D, which reconfirms the lateral growth of Ag. The height between steps is measured to be $0.24 \pm 0.02$ nm, which is a monatomic high step of a Ag(111) surface.

Unlike those mentioned above, STM images were collected when the potential was positively changed. Figure 4F exhibits an STM image when the potential was stepped to $-0.18$ V after the acquisition of an STM image in Figure 4E. Under this condition, the surface of an Ag adlayer is substantially rough, numerous particle-like islands are formed, and the step sites of a substrate are fluctuated. Primitively, these results were surprising and were not easily understood. However, the existence of chloride reveals a clue to unite these entanglements. If the potential is stepped to $0.12$ V, which is more clearly visualized in the inset of Figure 4F. Compared with the stripping of the Ag adlayer in pure electrolytes only with Ag$^+$ ions, the AgCl adsorption plays an important role in edge decoration.

Therefore, Ag adsorption and desorption on Au(111) in a pure HClO$_4$ solution are quite reversible processes which are supported by a series of symmetric peaks, as displayed in Figure 1.

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3.2.2. Ag Growth on Au(111) in the Presence of Cl$^-$. Figure 4A shows an STM image of Ag upd on Au(111) in 0.1 M HClO$_4$ and saturated AgCl obtained at 0.17 V. Ag islands are exclusively deposited around defects such as Au(111) steps, which are designated by arrows. It is interesting that Ag adsorbs only the lower portion of an Au(111) step, evincing that the lower part of the step is energetically more favorable than the upper part of the step. For comparison, STM images are obtained in pure 0.1 M HClO$_4$ at potentials between 0.0 and 0.5 V, in which any island is not found, indicating that the arrowed bright spots in Figure 4A are definitely Ag islands. The heights of the Ag islands are measured to be $0.34 \pm 0.02$ nm, which are much higher than that of an Ag upd island in the absence of chloride, which might be analyzed to maintain the bilayer structure composed of silver and chloride. Also, this bilayer structure of Ag and Cl rapidly moves toward a step-edge of Au(111), and it forms bumps at a step, which reveals the increase of surface mobility by chloride adsorption.}

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indicating that the processes of Ag adsorption and desorption on Au(111) in the presence of chloride ions are irreversible. The AgCl does not disappear until the potential becomes 0.35 V, and a smooth surface is disclosed again at this potential realm. In addition to the formation of AgCl, the adsorption of chloride at step sites induces the growth of streaky steps, manifested by arrows in Figure 4F, and the fluctuation of step-edges by the enhancement of surface mobility, as described in the previous report.31

3.3. Atom-Resolved STM Images of Ag Deposition on Au(111). To confirm the adlayer structures of Ag upd on Au(111) in a HClO₄ solution with or without Cl⁻ ions, we performed atom-resolved STM measurements on each system in the underpotential region, and various overlayer structures of Ag on Au(111) were reproducibly obtained in the presence or absence of chloride.

3.3.1. STM Imaging of Ag upd on Au(111) in the Absence of Cl⁻. Figure 5A shows an atomic STM image of an open Ag adlayer on Au(111) in 1 mM AgClO₄ and 0.1 M HClO₄ at E = 0.36 V. The distance between the brightest spots (a moiré pattern) is measured to be 1.15 ± 0.05 nm, which is 4 times longer than the interatomic distance of an Ag adlayer. Since the atomic rows of this structure are aligned with atomic sites of Au(111) with a (4 × 4) adlayer, and the unit cell is depicted with a rhombus in Figure 5A. Each spot is tentatively assigned to an Ag atom, although the well-known (36) Blum, L.; Huckaby, D. A. J. Electroanal. Chem. 1994, 375, 69.

3.3.2. STM Imaging of Ag upd on Au(111) in the Presence of Cl⁻. Figure 5A shows an atomic STM image of an Ag adlayer on Au(111) in a 0.1 M HClO₄ solution with saturated AgCl at 0.4 V. The distance between the spots is measured to be 28 ± 0.02 nm, which is the same as the interatomic distance of Au. The atomic rows are also parallel to those of Ag upd on Au(111) surface. Therefore, the observed structure is assigned to a (2 × 1) adlayer of Ag on Au(111). The bright spots have nearly equal heights of ~0.02 nm, and three lattice vectors are manifested by arrows and notations in Figure 5A.
this structure was observed at the iodide adsorptions on Ag(111)\textsuperscript{38} and on Au(111).\textsuperscript{39} In the case of chloride adsorption on Ag(111), however, a double-row structure was observed at the iodide adsorptions on Ag(111)\textsuperscript{38} and on Au(111).\textsuperscript{39,40} The lattice vectors of this structure are rotated 37° from those of an Au(111) surface, this structure is thus appointed to a \((\sqrt{3} \times \sqrt{3})R30°\) adlayer on Au(111).

Figure 6B shows an atomic STM image in 0.1 M HClO\textsubscript{4} and saturated AgCl at 0.2 V. The STM image reveals strong modulations and a moiré pattern. The spacing between bright spots is measured to be 1.26 ± 0.05 nm, which is \(\sqrt{19}\) times as large as the interatomic spacing of Au. Since the lattice vectors of this structure are rotated 37° from those of an Au(111) surface, this structure is thus assigned to a \((\sqrt{19} \times \sqrt{19})R37°\) adlattice. The vertical distance of bright spots, measured at \(0.05\) nm, is \(1.2 \times \) times as large as the interatomic distance of Au. The lattice vectors of this structure are closely matched to those of an Au(111) surface. Thus, this structure is assigned to a \((6 \times 6)\) adlattice. The vertical distance of bright spots, distributed randomly, is measured to be 0.07 ± 0.01 nm. The STM image, as shown in Figure 7D, is hardly found in other reports at the atomic level. One of the main reasons for the formation of this rough structure is the effect of chloride adsorption which is affirmed by the chloride adsorption on Ag(111).\textsuperscript{41} Chloride adsorbed on surfaces is considerably mobile, where it makes STM imaging unstable and poorly resolved under this potential region. Compensating the thermal drift of an STM scanner, therefore, we frequently observed the repositioning of bright spots within the acquisition time of one STM image.

4. Discussion

Compared with Ag upd on Au(111) in a pure HClO\textsubscript{4} solution, Ag depositions or stripping on Au(111) in the presence of chloride exhibits unique features. Although the low concentrations of silver and chloride are unavoidably employed, Ag adlayer structures on Au(111) explicitly reveal that they are strongly dependent on the chloride adsorption and the electrode potential.

4.1. Growth of Ag on Au(111). There are characteristic features in Ag growth on Au(111) whether chloride is present or not. In the presence of chloride, particularly, the enhanced surface mobility due to chloride adsorption helps the edge decoration and the lateral growth of Ag. 4.1.1. In Perchlorate. After the first peak (C\textsubscript{1} in Figure 1) of Ag upd, Ag islands are deposited on Au(111) terraces, and the heights of Ag islands are considerably lower than that of a bulk Ag(111) substrate. As the potential becomes more negative, the lateral growth of Ag controls the whole process of Ag deposition until a monolayer of Ag on Au(111) is accomplished. We also note that the existence of the second Ag adlayer in the underpotential range is associated with the shoulder peak in a cyclic voltammogram. As the potential is stepped to the positive value, terraces and steps of an Au(111) surface appear again. Thus, the desorption and adsorption of Ag are highly reversible, indicating that alloy formation between Ag and Au does not occur during potential cycles. 4.1.2. In Chloride. There are three different stages for Ag growth and a distinct feature for Ag desorption in a chloride-containing solution. The initial stage of Ag nucleation on Au(111) starts at defects that are energeti-

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on Ag(111), in which the driving force is the edge diffusion, closely coincides with our observations. There is a noticeable step fluctuation due to chloride adsorption on Au(111) and on Ag(111), in which the driving force is the edge diffusion, closely coincides with our observations. Therefore, the deposition and the desorption of Ag on an Au(111) substrate are definitely influenced by chloride ions.

4.2. Structural Changes. 4.2.1. In Perchlorate. After the first upd of Ag, an STM image reveals a (4 × 4) structure over the entire surface. Although perchlorate is well-known as a weakly adsorbed anion, the formation of an open adlattice elucidates the participation of anions by repulsive forces in the overlayer structure. Figure 8A shows a ball model of a (4 × 4) adlayer structure corresponding to the surface coverage 0.56, which is approximately matched to the surface coverage 0.42 acquired from electrochemical measurement. As the potential becomes near the second upd of Ag, a closely packed (1 × 1) structure starts to manifest on the Ag layer upon Au(111). Because the interatomic distance of Ag is in good agreement with that of Au, this can be interpreted as a model system of a (1 × 1) structure.

4.2.2. In Chloride. There are four characteristic structures which are clearly matched to features in a cyclic voltammogram shown in Figure 2. Around the C1 peak, an STM image reveals an open (√3 × √3)R30° adlattice. A ball model has the surface coverage 0.33 which is much higher than that obtained from a coulometric curve (0.03). This discrepancy might be originated from two possible sources. One is the difference of the potential of zero charge (pzc); an Au(111) electrode changes to more negative values during Ag deposition because the pzc values of Au(111) and Ag(111) differ by 1 V. The other is the anodic charge that is consumed to adsorb chloride ions over the Au(111) substrate or Ag adatoms. Although we did not quantify an accurate amount of chloride adsorption with the STM, which is short of information about chemical identities, the existence of anodic charge was easily recognized as the step fluctuation and the increased surface mobility were observed. As another aspect, bond formation between Ag and Cl is a spontaneous process because Ag–Cl (∼34.7 kJ/mol) and Ag–Cl (∼127 kJ/mol) have negative values, on the basis of the formation enthalpies for metal salts.

Additionally, thermal desorption experiments of Bowker et al. demonstrated that Cl and Ag formed strongly bound complexes which closely resembled AgCl. Therefore, the anodic charge due to the chloride adsorption must be compensated, and these sources cause the difference of surface coverage between an STM image and a coulometric curve.

As the potential becomes more negative around the peak C2, a (√19 × √19)R37° adlattice appears over the entire surface. A ball model that has the surface coverage 0.49, which is still higher than that from a coulometric curve (0.21), is shown in Figure 8B. The strong moiré pattern of a (√13 × √13)R46° adlattice begins to appear over the Au(111) surface after the C2 peak. A ball model that possesses the surface coverage 0.55 is depicted in Figure 8C. However, the charge density conforms to the surface coverage 0.32, which is approximately half of the value.

expected from the ball model. At a potential near the bulk deposition posterior to the peak C_4, a (6 × 6) structure starts to emerge. Figure 8D shows a ball model that points out the surface coverage 0.69, denoting that a complete monolayer of Ag is not formed within the underpotential range. Thus, a close-packed (1 × 1) overlayer of Ag is accomplished at −0.48 V, which is the region to fairly pass the bulk deposition. Even if the surface coverage between an electrochemical measurement and STM image shows a different behavior, unique features of a cyclic voltammogram are relevant to the phase transition of Ag on Au(111) for each adlayer structure acquired from STM images in the presence of chloride.

As another aspect, Ag atoms are capped with chloride anions that are easily adsorbed upon a Ag atom on Au(111), similar to previous results of Ag upd on iodine-modified Au(111) and Cu upd on iodine-modified Pt(111), indicating a bilayer structure composed of both Ag and Cl. Also, the high topography of Ag islands, as shown in Figure 4A, validates the landing of chloride anions on Ag atoms upon Au(111). We note that two kinds of bilayer structures are possible. One includes the direct binding of chloride on a Ag adatom in which the chloride anions are packed on atop sites of Ag atoms. This bilayer structure is shown in Figure 8E, depicted on the (√3 × √3)R30° structure as a side view and a top view. The other includes the positioning of chloride at a 3-fold site among Ag atoms, and Figure 8F depicts it as a side view and a top view. On the basis of the formation enthalpies of metal salts, the second structure is more favorable than the first one, since the system acquires the energetic gain of −254 kJ/mol by the formation of two additional Ag–Cl bonds. However, the definitive assignment of the bilayer structure must be studied further.

5. Conclusion

We conducted electrochemical and STM measurements to elucidate the process of Ag growth and the structures of Ag upd on Au(111) when chloride anions were present or absent. In the absence of chloride, an open (4 × 4) structure transforms into a close-packed (1 × 1) overlayer structure, and the system of Ag upd is reversible. In contrast to this, the introduction of chloride anions leads to distinctive features being exhibited in the cyclic voltammograms and STM images of Ag upd on Au(111). We observed four different structures of Ag on Au(111) in a chloride-containing solution as a function of potential and as a function of chloride adsorption in which (√3 × √3)R30°, (√19 × √19)R37°, (√13 × √13)R46°, and (6 × 6) adlayer structures are ascertained at each potential realm. These structures suggest that chloride anions strongly interact with Ag atoms during the upd process, and therefore, chloride plays an important role in the structure of a Ag adlayer on Au(111). Currently, we anticipate further research on the less investigated upd systems in the presence of anions in spite of the low solubility of metal salts (AgF, AgBr) in aqueous solutions.

Acknowledgment. This work was supported in part by the Korea Science and Engineering Foundation through the MICROS center at KAIST and by the Ministry of Information and Communication (Grant No. IMT 2000-B3-2).